



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Date July 22, 2008

In re the Application of

Syo-ichi TAKAMIZAWA et al.

Group Art Unit: 1792

Application No.: 10/578,369

Examiner: R. Kunemund

Filed: May 5, 2006

Docket No.: 127101

For: METHOD FOR PRODUCING SILICON EPITAXIAL WAFER

**LARGE ENTITY PETITION FOR 1st - 3rd EXTENSION
OF TIME UNDER 37 C.F.R. §1.136(a) AND
TRANSMITTAL OF FEE UNDER 37 C.F.R. §1.17**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

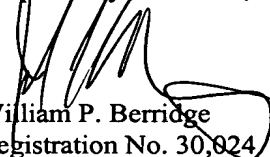
Sir:

Transmitted herewith is a response to the outstanding Official Action in the above-identified patent application. The shortened statutory period having expired June 25, 2008, an extension of time for a period of one month is hereby requested. Attached hereto is our Check No. 208099 in the amount of \$120 in payment for:

 X Extension fee for response within first month pursuant to §1.136(a) (\$120.00)
 Extension fee for response within second month pursuant to §1.136(a) (\$460.00)
 Extension fee for response within third or subsequent month pursuant to §1.136(a) (\$1050.00)

The Commissioner is hereby authorized to charge any additional fee or credit any overpayment associated with this communication to Deposit Account No. 15-0461.

Respectfully submitted,


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WPB:SQL/jls

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**DEPOSIT ACCOUNT USE
AUTHORIZATION**

Please grant any extension
necessary for entry;

Charge any fee due to our
Deposit Account No. 15-0461